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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/775,932	02/10/2004	Takafumi Morikawa	09792909-5805	3187
26263	7590	10/12/2005		EXAMINER
		SONNENSCHEIN NATH & ROSENTHAL LLP		CHEN, KIN-CHAN
		P.O. BOX 061080		
		WACKER DRIVE STATION, SEARS TOWER	ART UNIT	PAPER NUMBER
		CHICAGO, IL 60606-1080	1765	

DATE MAILED: 10/12/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	10/775,932	MORIKAWA ET AL.	
Examiner	Art Unit		
Kin-Chan Chen	1765		

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on ____.

2a) This action is **FINAL**. 2b) This action is non-final.

3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 1-4 is/are pending in the application.
4a) Of the above claim(s) _____ is/are withdrawn from consideration.

5) Claim(s) _____ is/are allowed.

6) Claim(s) 1-4 is/are rejected.

7) Claim(s) _____ is/are objected to.

8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.

10) The drawing(s) filed on _____ is/are: a) accepted or b) objected to by the Examiner.

 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).

11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) All b) Some * c) None of:
1. Certified copies of the priority documents have been received.
2. Certified copies of the priority documents have been received in Application No. _____.
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1) Notice of References Cited (PTO-892)
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____.
4) Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____.
5) Notice of Informal Patent Application (PTO-152)
6) Other: _____.

DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

2. Claims 1-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Olsen (US 2004/0175961) or Kraus et al. (US 2004/0242021).

Olsen or Kraus teaches a method for semiconductor device fabrication. Olsen or Kraus teaches forming a nitrogen-containing oxide film on a substrate as a gate insulating film. The gate insulating film may be annealed in an oxygen-free, inert atmosphere. The gate insulating film may be annealed in an atmosphere containing oxygen. An electrode film may be formed in the gate insulating film which has been annealed twice. The annealing may be carried out in a pressure-reduced oxygen atmosphere. The annealing may be carried in various temperatures. See abstract, [0046] and [0047] of Olsen, or Fig. 3 and [0039] of Kraus.

The claimed invention differs from Olsen or Kraus by teaches applying two annealing steps in reversed order. However, in the absence of showing criticality, it would have been obvious to one with ordinary skilled in the art to apply two annealing steps in the foregoing order or in reversed order.

3. Claims 1-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Visokay et al. (US 6,821,873).

Visokay teaches a method for semiconductor device fabrication. Visokay teaches forming a nitrogen-containing oxide film on a substrate as a gate insulating film. The gate insulating film may be annealed in an oxygen-free, inert atmosphere. The gate insulating film may be annealed in an atmosphere containing oxygen. An electrode film may be formed in the gate insulating film which has been annealed twice. The annealing may be carried out in a pressure-reduced oxygen atmosphere. The annealing may be carried in various temperatures. See abstract, col. 2, line 37 through col. 3, line 25.

The claimed invention differs from Visokay by teaches applying two annealing steps in reversed order. However, in the absence of showing criticality, it would have been obvious to one with ordinary skilled in the art to apply two annealing steps in the foregoing order or in reversed order because it is expected to have similar results in both ways.

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kin-Chan Chen whose telephone number is (571) 272-1461. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent

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Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

October 6, 2005



Kin-Chan Chen
Primary Examiner
Art Unit 1765

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